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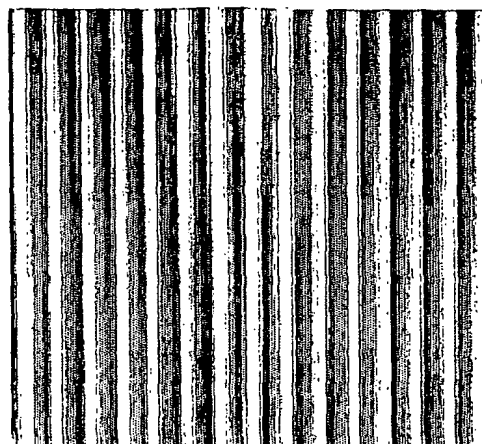
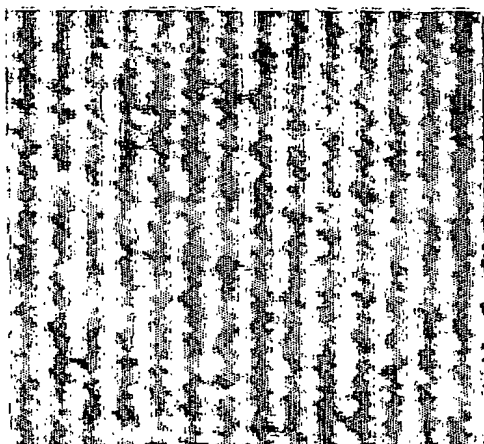
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- (71) Applicant (*for all designated States except US*): **INFM ISTITUTO NAZIONALE PER LA FISICA DELLA MATERIA** [IT/IT]; Corso F. Perrone 24, I-16152 GENOVA (IT).
- (72) Inventors; and
- (75) Inventors/Applicants (*for US only*): **CAPUTO, Roberto** [IT/IT]; Via Parigi 21, I-87036 RENDE (Cosenza) (IT). **UMETON, Cesare** [IT/IT]; Via Tevere 68, I-87036 RENDE (Cosenza) (IT). **VELTRI, Alessandro** [IT/IT]; Via P. Borsellino - Fabbricato S.E.M., s.n., I-87100 COSENZA (IT). **SUKHOV, Andrey** [RU/RU]; pr. Karamzina 9 - Apt. 60, MOSCOW, 117463 (RU). **TABIRYAN, Nelson** [AM/US]; 809 South Orlando Avenue - Suite I, WINTER PARK, Florida 32789 (US).
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- *as to applicant's entitlement to apply for and be granted a patent (Rule 4.17(ii)) for the following designations* AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA,

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(54) Title: **HOLOGRAPHIC DIFFRACTION GRATING, PROCESS FOR ITS PREPARATION AND OPTO-ELECTRONIC DEVICES INCORPORATING IT**



(57) Abstract: Composite polymer/liquid crystal material having a holographic grating structure formed by an alternating ordered succession of polymer layers and nematic liquid crystal layers. The nematic liquid crystal layers comprise an ordered nematic monophasic region which is substantially free from liquid crystal droplets.

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